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PATENT
YOR919980056US1
IBM-304

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of	:	Marie Angelopoulos
Serial Number	:	09/256,034
Filing Date	:	February 23, 1999
Examiner	:	John S. V. Chu
Group Art Unit	:	1752
For	:	MULTILAYERED RESIST SYSTEMS USING TUNED POLYMER FILMS AS UNDERLAYERS AND METHODS OF FABRICATION THEREOF

TO: The Honorable Commissioner of Patents
Post Office Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Official Action dated September 6, 2006, please amend the above-identified application as follows:

IN THE CLAIMS

Cancel Claim 6.

REMARKS

Applicants have reviewed the Official Action noted above and have amended Claim 1 to include "photosensitive elements" for the resist material used in the method. The thickness of the layers and the units thereof have also been included in Claim 1. These insertions were implemented to